

| Application/Control No. | Applicant(s)/Patent under Reexamination | |
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| 10/565,266 | WONG, KWOK HUNG | |
| Examiner | Art Unit | |
| Hwei-Siu C. Payer | 3724 | |

| SEARCHED | | | | | |
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| Class | Subclass | Date | Examiner | | |
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| SEARCH NOTES (INCLUDING SEARCH STRATEGY) | | | | |
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